

67,200-1121
2002-1020/1093

DECLARATION FOR PATENT APPLICATION

As a below-named inventor, We hereby declare that:

My residence, post office address and citizenship are as stated below next to my name,

I believe I am the original, first and sole inventor (if only one name is listed below) or an original, first and joint inventor (if plural names are listed below) of the subject matter which is claimed and for which a patent is sought on the invention entitled

METHOD TO IMPROVE POST WAFER ETCH CLEANING PROCESS

the specification of which X is attached hereto.
_____ was filed on _____ as
Application Serial No.
And was amended on _____
(If applicable)

I hereby state that I have reviewed and understand the contents of the above-identified specification, including the claims, as amended by any amendments referred to above.

I acknowledge the duty to disclose information which is material to the examination of this application in accordance with Title 37, Code of Federal Regulations, §1.56, a copy of which is attached.

I hereby claim foreign priority benefits under Title 35, United States Code, §119 of any foreign application(s) for patent or inventor's certificate listed below and have also identified below any foreign application(s) for patent or inventor's certificate having a filing date before that of the application on which priority is claimed:

Prior Foreign Application(s)

Priority Claimed

Number	Country	Day/Month/Year	(Yes)	(No)
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Number	Country	Day/Month/Year	(Yes)	(No)
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Number	Country	Day/Month/Year	(Yes)	(No)
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